## Electric field modulation of magnetization in MgO/Co/Pt structure

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Electric field gating is a novel means to manipulate magnetization and attracts attention because of its low power consumption compared to conventional ones. A field effect capacitor with an ultra-thin metallic magnet as a bottom electrode is used to change its magnetic properties. Particularly in Co/Pt system, which is widely known as a promising candidate for high-density storage media, its Curie temperature and perpendicular magnetic anisotropy are electrically controllable [1,2]. In this study, we investigate the change in a saturation magnetization  $M_s$  using a Co/Pt system under an application of electric field.

To probe the change in  $M_s$  by an electric field, we measured the change in the anomalous Hall resistance  $R_{\text{Hall}}$ , which is proportional to the perpendicular component of magnetization. The sputter-deposited MgO(2.0 nm)/Co(0.33 nm)/Pt(2.4 nm)/Ta(2.5 nm) on GaAs (001) substrate was used for the experiment. First the Hall bar geometry was fabricated from the film using standard photolithography technique and Ar ion milling. Subsequently, 50-nm HfO<sub>2</sub> insulator layer and Au (100 nm)/Cr (3 nm) gate electrode were formed on the Hall bar to apply a gate electric field to the bottom Co layer. The HfO<sub>2</sub> layer was deposited by atomic layer deposition. In our setup, a positive (negative) gate voltage  $V_{\text{G}}$  increases (decreases) electrons at the surface of the Co layer. We measured the Hall resistance under various  $V_{\text{G}}$  at 5 K.

Figure 1 shows  $R_{\text{Hall}}(V_{\text{G}})/R_{\text{Hall}}(V_{\text{G}}=0)$  as a function of  $V_{\text{G}}$ , where  $R_{\text{Hall}}(V_{\text{G}})$  is the Hall resistance at  $V_{\text{G}}$ . The positive slope in the Fig. 1 indicates that  $M_{\text{s}}$  increases with increasing applied  $V_{\text{G}}$  if  $R_{\text{Hall}}$  is assumed to be proportional to  $M_{\text{s}}$ . In the presentation, we will discuss the mechanism of the electric field controlled magnetization in the MgO/Co/Pt system.

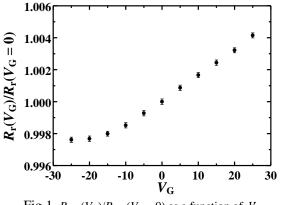


Fig.1.  $R_{\text{Hall}}(V_{\text{G}})/R_{\text{Hall}}(V_{\text{G}}=0)$  as a function of  $V_{\text{G}}$ .

[2] K. Yamada et al., Appl. Phys. Exp. 6, 073004 (2013).

<sup>[1]</sup> D. Chiba et al., Nature Mater. 10, 853 (2011).